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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/675,697	09/30/2003	Amanda Baer	HSJ9-2003-0032US1 (0107-0	6166
7	590 09/02/2005		EXAM	INER
ATTN: John J. Oskorep			ARANCIBIA, MAUREEN GRAMAGLIA	
One Magnificent Mile Center				
Suite 1400			ART UNIT	PAPER NUMBER
980 N. Michigan Avenue			1763	
Chicago II 6				

DATE MAILED: 09/02/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

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Ţ,	Application No.	Applicant(s)	
Advisory Action	10/675,697	BAER ET AL.	
Before the Filing of an Appeal Brief	Examiner	Art Unit	
	Maureen G. Arancibia	1763	
The MAILING DATE of this communication appe	ars on the cover sheet with the c	correspondence address	
THE REPLY FILED 22 August 2005 FAILS TO PLACE THIS A	PPLICATION IN CONDITION FOR	R ALLOWANCE.	
 The reply was filed after a final rejection, but prior to or o this application, applicant must timely file one of the folloplaces the application in condition for allowance; (2) a No (3) a Request for Continued Examination (RCE) in comp following time periods: The period for reply expires 3 months from the mailing date of 	owing replies: (1) an amendment, a ptice of Appeal (with appeal fee) in liance with 37 CFR 1.114. The repl	ffidavit, or other evidence, which compliance with 37 CFR 41.31; o	
b) The period for reply expires on: (1) the mailing date of this Adv event, however, will the statutory period for reply expire later the Examiner Note: If box 1 is checked, check either box (a) or (b).	an SIX MONTHS from the mailing date o ONLY CHECK BOX (b) WHEN THE FI	f the final rejection.	
MONTHS OF THE FINAL REJECTION. See MPEP 706.07(f) Extensions of time may be obtained under 37 CFR 1.136(a). The date on been filed is the date for purposes of determining the period of extension a CFR 1.17(a) is calculated from: (1) the expiration date of the shortened sta above, if checked. Any reply received by the Office later than three months earned patent term adjustment. See 37 CFR 1.704(b). NOTICE OF APPEAL	which the petition under 37 CFR 1.136(a and the corresponding amount of the fee. atutory period for reply originally set in the s after the mailing date of the final rejection	The appropriate extension fee under 37 final Office action; or (2) as set forth in on, even if timely filed, may reduce any	
 The Notice of Appeal was filed on A brief in composition of filing the Notice of Appeal (37 CFR 41.37(a)), or any e Since a Notice of Appeal has been filed, any reply must band the AMENDMENTS 	xtension thereof (37 CFR 41.37(e)), to avoid dismissal of the appeal.	
 The proposed amendment(s) filed after a final rejection, (a) They raise new issues that would require further co (b) They raise the issue of new matter (see NOTE belo (c) They are not deemed to place the application in belo appeal; and/or (d) They present additional claims without canceling a 	nsideration and/or search (see NO w); tter form for appeal by materially re corresponding number of finally re	TE below); educing or simplifying the issues fo	
NOTE: (See 37 CFR 1.116 and 41.33(a)). 4. The amendments are not in compliance with 37 CFR 1.1		nmpliant Amendment (PTOL-324)	
5. 🔲 Applicant's reply has overcome the following rejection(s		,	
7. For purposes of appeal, the proposed amendment(s): a) how the new or amended claims would be rejected is pro The status of the claim(s) is (or will be) as follows: Claim(s) allowed: Claim(s) objected to: Claim(s) rejected: 1,2,4,6,8-16,18 and 21-30. Claim(s) withdrawn from consideration:		ill be entered and an explanation o	
AFFIDAVIT OR OTHER EVIDENCE			
 The affidavit or other evidence filed after a final action, because applicant failed to provide a showing of good an and was not earlier presented. See 37 CFR 1.116(e). 	d sufficient reasons why the affida	vit or other evidence is necessary	
 The affidavit or other evidence filed after the date of filing entered because the affidavit or other evidence failed to a showing a good and sufficient reasons why it is necessar The affidavit or other evidence is entered. An explanation 	overcome <u>all</u> rejections under appe ry and was not earlier presented. S	al and/or appellant fails to provide See 37 CFR 41.33(d)(1).	

REQUEST FOR RECONSIDERATION/OTHER

11. 🖾 The request for reconsideration has been considered but does NOT place the application in condition for allowance because: See Continuation Sheet

12. Note the attached Information Disclosure Statement(s). (PTO/SB/08 or PTO-1449) Paper No(s).

13. Other: _____.

PARVIZ HÁSSANZADEH SUPERVISORY PATENT EXAMINER Continuation of 11. does NOT place the application in condition for allowance because: Applicant's arguments filed 22 August 2005 nave been fully considered but they are not persuasive. In response to Applicant's argument that Sasaki does not teach a method of defining a stripe height, the Examiner disagrees. Sasaki expressly teaches a method of defining a stripe height (MR height; Column 12, Lines 55-62) and a track width (Column 13, Lines 33-35). In response to Applicant's argument that there is no motivation to use the CMP method of Lille in the formation of the stripe height (which the Examiner maintains is taught by Sasaki), the Examiner recognizes that obviousness can only be established by combining or modifying the teachings of the prior art to produce the claimed invention where there is some teaching, suggestion, or motivation to do so found either in the references themselves or in the knowledge generally available to one of ordinary skill in the art. See In re Fine, 837 F.2d 1071, 5 USPQ2d 1596 (Fed. Cir. 1988) and In re Jones, 958 F.2d 347, 21 USPQ2d 1941 (Fed. Cir. 1992). In this case, the motivation for using the CMP method of Lille to remove either of the photoresists taught by Sasaki (i.e. that used in defining the stripe height or that used in defining the track width), as taught by Lille (Paragraph 53), would have been that CMP can successfully remove the resist even when other materials have been deposited on it. This motivation would apply in modifying the method of defining the stripe height and the method of defining the track width taught by Sasaki, since in both cases, the photoresist is removed.

Maureer & Chancil